

# Masahiro Hori

## List of Publications by Year in descending order

Source: <https://exaly.com/author-pdf/9858443/publications.pdf>

Version: 2024-02-01

11

papers

77

citations

1684188

5

h-index

1720034

7

g-index

11

all docs

11

docs citations

11

times ranked

60

citing authors

#	ARTICLE	IF	CITATIONS
1	Single-electron quantization at room temperature in a-few-donor quantum dot in silicon nano-transistors. <i>Applied Physics Letters</i> , 2017, 110, .	3.3	22
2	Analysis of electron capture process in charge pumping sequence using time domain measurements. <i>Applied Physics Letters</i> , 2014, 105, 261602.	3.3	17
3	Charge Pumping Under Spin Resonance in $\text{Si}_{\text{Si}}$ (charge pumping current) = $\frac{\partial \text{ETQq}_1}{\partial \text{Tf}} \cdot \frac{1}{\text{rgBT}} \cdot \frac{1}{\text{Overlock}} \cdot \frac{1}{50} \cdot \frac{6^{3.8}}{5^{13}} \cdot \frac{1}{\text{Td}}$ (stretchy="false")	3.3	17
4	Direct observation of electron emission and recombination processes by time domain measurements of charge pumping current. <i>Applied Physics Letters</i> , 2015, 106, .	3.3	10
5	Electrical activation and electron spin resonance measurements of arsenic implanted in silicon. <i>Applied Physics Letters</i> , 2015, 106, 142105.	3.3	5
6	Improvement of charge-pumping electrically detected magnetic resonance and its application to silicon metal-oxide-semiconductor field-effect transistor. <i>Applied Physics Express</i> , 2017, 10, 015701.	2.4	5
7	Electron aspirator using electron-electron scattering in nanoscale silicon. <i>Nature Communications</i> , 2018, 9, 4813.	12.8	5
8	Charge pumping EDMR towards charge/spin manipulation in silicon at room temperature. , 2016, , .	0	0
9	Detection and Characterization of Single Near-Interface Oxide Traps with the Charge Pumping Method. , 2018, , .	0	0
10	Detection of arsenic donor electrons using gate-pulse-induced spin-dependent recombination in silicon transistors. <i>Applied Physics Letters</i> , 2021, 118, 263504.	3.3	0
11	Critical conductance of two-dimensional electron gas in silicon-on-insulator metal-oxide-semiconductor field-effect transistor. <i>Applied Physics Express</i> , 2021, 14, 104003.	2.4	0